SHIGA7.055APC PATENT

REQUEST FOR CORRECTED FILING RECEIPT

Applicant

Hirayama et al.

Appl. No.

10/590,046

Filed

: June 15, 2007

For

BASE MATERIAL FOR

PATTERN-FORMING MATERIAL, POSITIVE RESIST COMPOSITION AND METHOD OF RESIST

PATTERN FORMATION

Art Unit

1752

Commissioner for Patents
P.O. Box 1450
Office of Initial Patent Examination
Customer Service Center
Alexandria, VA 22313-1450

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I hereby certify that this correspondence, and any other attachment noted on the automated Acknowledgement Receipt, is being transmitted from within the Pacific Time zone to the Commissioner for Patents via the EFS Web server on:

June 4, 2008_

Neil S. Bartfeld, Ph.D., Reg. No. 39,901

Dear Sir:

Applicants hereby request that the Official Filing Receipt, a copy of which is enclosed, be corrected to reflect the title, BASE MATERIAL FOR PATTERN-FORMING MATERIAL, POSITIVE RESIST COMPOSITION AND METHOD OF RESIST PATTERN FORMATION. Presently, the Filing Receipt incorrectly shows the title as BASE MATERIAL FOR PATTERN-FORMING MATERIAL, POSITIVE RESIST COMPOSITION AND METHOD OF RESIST FORMATION.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated:

By:

Neil S. Bartfeld, Ph.D.

Registration No. 39,901

Agent of Record

Customer No. 20,995

(619) 235-8550



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	APPLICATION	FILING or	GRP ART				
l	NUMBER	371(c) DATE	UNIT	FIL FEE RECD	ATTY DOCKET NO	TOT CLAIMS	IND CLAIMS
	10/590,046	06/15/2007	1752	1030	SHIGA7.055APC	15	2

CONFIRMATION NO. 5635 FILING RECEIPT

20995 KNOBBE MARTENS OLSON & BEAR LLP 2040 MAIN STREET FOURTEENTH FLOOR IRVINE, CA 92614

NAME ALE DITATION DE MANTE DE LA TRANSPORTION DE LA COMPOSITION DE LA COMPOSITION DE LA COMPOSITION DE LA COMP

Date Mailed: 02/15/2008

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verily the accuracy of the data presented on this receipt. If an error is noted on this Filling Receipt, please write to the Office of Initial Patent Examination's Filling Receipt Corrections. Please provide a copy of this Filling Receipt with the changes noted thereon, if you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filling Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filling Receipt incorporating the requested corrections

Applicant(s)

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Power of Attorney: The patent practitioners associated with Customer Number 20995

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP05/01798 02/08/2005

Foreign Applications

JAPAN 2004-045043 02/20/2004 JAPAN 2004-045044 02/20/2004 JAPAN 2004-182300 06/21/2004 JAPAN 2004-182301 06/21/2004

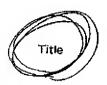
If Required, Foreign Filing License Granted: 08/29/2007

The country code and number of your priority application, to be used for filling abroad under the Paris Convention, is **US 10/590,046**

Projected Publication Date: Not Applicable

Non-Publication Request: No Early Publication Request: No

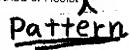
page 1 of 3



Base Material for Pattern Forming Material, Positive Resist Composition and Method of Resist

Preliminary Class

430



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Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent In a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process simplifies the filing of patent applications on the same invention in member countries, but does not result in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where gatent protection is desired.

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